EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	701	((TADAHIRO) near2 (OHMI)).INV.	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 15:53
S2	408	S1 and ("silicon carbide" or impurit$4 or clean$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 15:55
S3	1	S1 and ("silicon carbide" with impurit$4 with clean $4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 15:55
S4	583	((TADAHIRO) near2 (OHMI)).INV.	EPO; JPO; DERWENT	OR	ON	2009/02/10 15:55
S5	1	S3 and ("silicon carbide" with impurit$4 with clean $4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 15:55
S6	1	S3 and ("silicon carbide" with clean$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 15:56
S7	2	S1 and ("silicon carbide" with clean$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 15:56
S8	51	((AKINOBU) near2 (TERAMOTO)).INV.	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 15:56
S9	38	S8 and (impurit$4 or clean $4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 15:57
S10	9	S8 and (impurit$4 with (remov$4 or clean$4))	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 15:58
S11	2	("20060234058").PN.	US-PGPUB; USPAT; USOCR; DERWENT	OR	OFF	2009/02/10 15:59
S12	146	((AKINOBU) near2 (TERAMOTO)).INV.	EPO; JPO; DERWENT	OR	ON	2009/02/10 16:00
S14	0	S12 and ("silicon carbide" same clean$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:01
S15	0	S12 and (impurit$4 with (remov$4 or clean$4))	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:01
S16	1	((SUMIO) near2 (SANO)).INV.	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:01
S17	2	((SUMIO) near2 (SANO)).INV.	EPO; JPO; DERWENT	OR	ON	2009/02/10 16:01
S18	287	((TADAHIRO) near2 (OHMI)).as.	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:04
S19	0	S18 and ("silicon carbide" with impurit$4 with clean $4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:04

S20	4	S18 and ("silicon carbide")	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:05
S21	1	admap.as.	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:05
S22	5182	mitsui.as.	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:05
S23	0	S22 and ("silicon carbide" with impurit$4 with clean$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:06
S24	223	S22 and ("silicon carbide")	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:06
S25	0	S22 and ("silicon carbide" with clean$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:06
S26	2	US-20020005213-$.DID.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2009/02/10 16:11
S27	0	("2002/0005213").URPN.	USPAT	OR	ON	2009/02/10 16:11
S28	0	("2002/0005213").URPN.	USPAT	OR	ON	2009/02/10 16:11
S29	1	("6419757").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/02/10 16:13
S30	4	("5589116" | "5770324" | "5942454").PN. OR ("6419757").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:13
S31	2	US-272006D-$.DID. OR JP-11008216-$.DID. OR JP-200386792-$.DID. OR JP-6128036-$.DID.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2009/02/10 16:14
S32	6	US-5341781-$.DID. OR JP-11008216-$.DID. OR JP-200386792-$.DID. OR US-1534196-$.DID.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2009/02/10 16:15
S33	278	(silicon near2 carbide) with impurit$4 with (clean$4 or remov$4 or reduc$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:44
S34	34	S33 with acid	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 16:44
S35	0	("1925396").URPN.	USPAT	OR	ON	2009/02/10 16:48
S36	47	clean$4 with (sulfuric near2 acid) with (hydrogen peroxide) with solution with (pH or volume or ratio)	USPAT	OR	ON	2009/02/10 17:05

S37	108	clean$4 with (sulfuric near2 acid) with (hydrogen peroxide) with solution with (pH or volume or ratio)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 17:05
S38	18	S37 with (silicon or semiconductor)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 17:05
S39	17	clean$4 with (sulfuric near2 acid) with (hydrogen peroxide) with solution with (pH)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/10 17:14
S40	2952	(134/2).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/02/11 09:15
S41	301	S40 and (((silicon near2 carbide) or SiC or silicon) with (hydrofluoric or hydrochloric or sulfuric or "hydrogen peroxide" or HF or HCl or HSO))	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:18
S42	123	S41 and (metal near4 (contaminant or impurit$4))	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:18
S43	14	S40 and (((silicon near2 carbide) or SiC) with (hydrofluoric or hydrochloric or sulfuric or "hydrogen peroxide" or HF or HCl or HSO))	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:29
S44	2776	(134/3).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/02/11 09:30
S45	7	S44 and (((silicon near2 carbide) or SiC) with (hydrofluoric or hydrochloric or sulfuric or "hydrogen peroxide" or HF or HCl or HSO))	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:30
S46	517	(134/1.2).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/02/11 09:31
S47	1	S46 and (((silicon near2 carbide) or SiC) with (hydrofluoric or hydrochloric or sulfuric or "hydrogen peroxide" or HF or HCl or HSO))	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:31
S48	2576	(134/42).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/02/11 09:32

S49	6	S48 and (((silicon near2 carbide) or SiC) with (hydrofluoric or hydrochloric or sulfuric or "hydrogen peroxide" or HF or HCl or HSO))	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:32
S50	2396	(134/1).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/02/11 09:32
S51	18	S50 and (((silicon near2 carbide) or SiC) with (hydrofluoric or hydrochloric or sulfuric or "hydrogen peroxide" or HF or HCl or HSO))	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:32
S52	16	silicon with (sulfuric near2 acid) with (hydrogen peroxide) with (pH)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:34
S53	17	clean$4 with (sulfuric near2 acid) with (hydrogen peroxide) with solution with (pH)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:34
S54	11	clean$4 with (sulfuric near2 acid) with (hydrogen near2 peroxide) with solution with (pH)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:35
S55	21	clean$4 same (sulfuric near2 acid) same (hydrogen near2 peroxide) same solution with (pH)	EPO; JPO; DERWENT	OR	ON	2009/02/11 09:36
S56	226	(sulfuric near2 acid) with (hydrogen near2 peroxide) with solution with (pH)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:46
S57	5	S56 with silicon	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:47
S58	144	(sulfuric near2 acid) with (hydrogen near2 peroxide) with solution with (pH) with ("1" or "2" or "3" or "4")	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:48
S59	130	S58 and (clean$4 or remov$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:48
S60	6	S59 and "134".clas.	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:49
S61	4	S59 and "510".clas.	US-PGPUB; USPAT; USOCR	OR	ON	2009/02/11 09:50

| S66 | 43 | (("sulfuric peroxide mixture" or SPM) near7 pH) | US-PGPUB; USPAT; USOCR | OR | ON | 2009/02/11 10:12 |
| S67 | 3 | ("sulfuric peroxide mixture" with pH) | US-PGPUB; USPAT; USOCR | OR | ON | 2009/02/11 10:13 |

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